

Special Issue

Thermal Analysis and Multi-Scale Modeling for Chemical Processes

Message from the Guest Editors

The purpose of this Special Issue is to present a collection of papers that reflect recent developments in the field of multi-scale modeling of chemical processes and highlight the essential role of thermal analysis in understanding the behavior of various chemical processes.

- Differential scanning calorimetry (DSC)
- Thermogravimetric analysis (TGA)
- Process simulation
- Reaction kinetics
- Scaling

Guest Editors

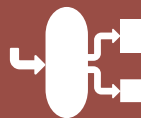
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Prof. Dr. Nobuyoshi Koga

Prof. Dr. Luis A. Perez-Maqueda

Deadline for manuscript submissions

closed (15 August 2023)



Processes

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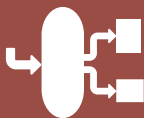


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Editor-in-Chief

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